

	L #	Hits	Search Text	DBs
1	L1	305993	"438"/\$.ccls. "430"/\$.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
2	L2	1114	1 and (chemical\$2 near amplified near resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
3	L3	415	2 and pattern\$3 near (irradiat\$3 or expos\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
4	L4	306	3 and acid near generat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
5	L5	72	4 and (onium near salt)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
6	L6	2	5 and perfluoropolyether	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
7	L7	13	5 and (acetic near acid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
8	L8	496	(endo-masayuki or sasago- masaru).in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
9	L9	97	8 and (chemical\$2 near amplified near resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
10	L10	91	9 and acid near generat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
11	L11	5	10 and perfluoropolyether	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
12	L12	7131	(pattern\$3 near resist).ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
13	L13	133	12 and (chemical\$2 near amplified near resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
14	L14	2	13 and (acid near generat\$3 near solution)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
15	L15	1707	pattern\$3 and (chemical\$2 near amplified near resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
16	L17	1	16 and perfluoropolyether	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
17	L18	1	16 and (onium near salt)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
18	L16	15	15 and (acid near generat\$3 near solution)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
19	L19	48666	(pattern\$3 near resist)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
20	L20	34862	19 and (irradiat\$3 or expos\$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB

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21	L21	3056	20 and acid near generat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
22	L22	766	21 and (onium near salt)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
23	L24	1	23 and perfluoropolyether	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
24	L23	175	22 and (acetic near acid)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
25	L25	299	20 and (polyacrylic or (polystyrene near sulfonic)) near acid	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB
26	L26	3	25 and perfluoropolyether	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM TDB